

Review of Polymer Solutions for Near-Field Electrospinning with Spatial Control

Antonio Osamu Katagiri Tanaka, Héctor Alán Aguirre Soto

Abstract

Lorem ipsum dolor sit amet, consectetur adipiscing elit, sed do eiusmod tempor incididunt ut labore et dolore magna aliqua. Ut enim ad minim veniam, quis nostrud exercitation ullamco laboris nisi ut aliquip ex ea commodo consequat. Duis aute irure dolor in reprehenderit in voluptate velit esse cillum dolore eu fugiat nulla pariatur. Excepteur sint occaecat cupidatat non proident, sunt in culpa qui officia deserunt mollit anim id est laborum.

Contents

1	Introduction	1
2	NFES	2
3	Polymer Solution and Process Parameters	9
4	Applications	9
5	Fiber Characterization	9
6	Conclusion	9
	References	9

1. Introduction

Lorem ipsum dolor sit amet, consectetur adipiscing elit, sed do eiusmod tempor incididunt ut labore et dolore magna aliqua. Ut enim ad minim veniam, quis nostrud exercitation ullamco laboris nisi ut aliquip ex ea commodo consequat. Duis aute irure dolor in reprehenderit in voluptate velit esse cillum dolore eu fugiat nulla pariatur. Excepteur sint occaecat cupidatat non proident, sunt in culpa qui officia deserunt mollit anim id est laborum.

Email addresses: oskatagiri@gmail.com (Antonio Osamu Katagiri Tanaka), alan.aguirre@tec.mx (Héctor Alán Aguirre Soto)

2. NFES

Lorem ipsum dolor sit amet, consectetur adipiscing elit, sed do eiusmod tempor incididunt ut labore et dolore magna aliqua. Ut enim ad minim veniam, quis nostrud exercitation ullamco laboris nisi ut aliquip ex ea commodo consequat. Duis aute irure dolor in reprehenderit in voluptate velit esse cillum dolore eu fugiat nulla pariatur. Excepteur sint occaecat cupidatat non proident, sunt in culpa qui officia deserunt mollit anim id est laborum.

Table 1: Electrospun Polymer Solutions - Solution and Process Parameters

Polymer(s)	Solvent(s)	NFES Variant	Process Parameters and Fiber Characterization	Ref.
Poly(ethylene oxide) (PEO)	Deionized water	Low-Voltage NFES	Solution Concentration: 1, 2, and 3 <i>wt%</i> PEO Nozzle: 27 gauge type 304; stainless steel needle Solution deposition rate: lower than $1\mu L/h$ Nozzle-to-substrate distance: $1mm$ Substrate composition: Pyrolyzed SU-8 carbon and Si Applied voltage: polymer jet initiated at 400-600 V and dispensed at 200-400 V x-y stage velocity: $10-40mm/s$ Fiber Diameter: $50-425nm$ Distance between adjacent fibers: <i>Not determined</i>	[1]
Poly[2-methoxy-5-(2-ethylhexyloxy)-1,4-phenylenevinylene] (MEH-PPV) with Poly(ethylene oxide) (PEO)	acetonitrile toluene mixture (65/35); acetic acid toluene (17/83); pure toluene	<i>Not determined</i>	Solution Concentration: $10mg$ of MEH-PPV in $2mL$ of toluene; $500mL$ of MEH-PPV solution with $250mg$ of PEO in $3.5mL$ of acetonitrile; $500mL$ of MEH-PPV solution with $250mg$ of PEO in $3mL$ of acetic acid / toluene (17 / 83). The resulting MEH-PPV/PEO concentration is 1:100 Nozzle: mm-diameter tip Tungsten spinneret in a 26 gauge needle Solution deposition rate: $50\mu L/h$ Nozzle-to-substrate distance: $500\mu m$ Substrate composition: SiO ₂ /Si (oxide thickness = 800 nm) Applied voltage: around $1.3kV$ x-y stage velocity: $50cm/s$ Fiber Diameter: $100nm$ Distance between adjacent fibers: around $100\mu m$	[2]

Continued on next page

<i>Table 1 continued</i>				
	Poly(ethylene oxide) (PEO)	Water	Scanning Tip Electrospinning and NFES	Solution Concentration: 7wt% PEO [3] Nozzle: Needle outer diameter of 200 μm and inner diameter of 100 μm Solution deposition rate: 0.1 $\mu L/h$ Nozzle-to-substrate distance: 500 μm Substrate composition: <i>Not determined</i> Applied voltage: polymer jet initiated at 1.5 kV and dispensed at 600V x-y stage velocity: 120mm/s Fiber Diameter: 709 \pm 131nm; 49-74nm when applied voltage is 800V Distance between adjacent fibers: <i>Not determined</i> Notes: 108m yield in 15min with a fiber diameter of 709 \pm 131nm
4	Poly(vinylidene fluorid) (PVDF)	N,N Dimethyl-formamide (DMF)	Helix Electrohydrodynamic Printing (HE-printing)	Solution Concentration: 1.8g PVDF in 4.1g of DMF and 4.1g of acetone. The resulting concentration is 18% PVDF. [4] Nozzle: Needle outer diameter of 510 μm and inner diameter of 260 μm Solution deposition rate: 400nL/min Nozzle-to-substrate distance: 10-50mm Substrate composition: Poly(dimethylsiloxane) (PDMS) on Ecoflex Applied voltage: 1.5–3kV x-y stage velocity: 0-400mm/min Fiber Diameter: about 1.5-3 μm Distance between adjacent fibers: <i>Not determined</i>

Continued on next page

<i>Table 1 continued</i>				
Polyhedral Oligomeric Silsesquioxane- Poly(Carbonate- Urea)Urethane (POSS-PCU) and Polyhe- dral Oligomeric Silsesquioxane Poly(Caprolactone- Poly(Carbonate- Urea)Urethane) (POSS-PCL- PCU)	Dimethyl acetamide (DMAC) and 1-Butanol	Electrohydro- dynamic 3D Print-patterning or Electrohydro- dynamic Jetting	Solution Concentration: POSS-PCU and POSS-PCL-PCU used in 20%w/w concentration in DMAC Nozzle: needle of 750 μm in diameter Solution deposition rate: less than 1 $\mu L/min$ Nozzle-to-substrate distance: about between 500 μm to 2mm Substrate composition: <i>Not determined</i> Applied voltage: 8.0-10.0kV x-y stage velocity: 10mm/s Fiber Diameter: 5-50 μm Distance between adjacent fibers: 250 μm	[5]
Poly(ethylene ox- ide) (PEO)	Distilled water	Electrohydro- dynamic Writing or Mechano- electrospinning (MES)	Solution Concentration: 6wt% PEO Nozzle: <i>Not determined</i> Solution deposition rate: 1200nL/min Nozzle-to-substrate distance: 7.5mm Substrate composition: <i>Not determined</i> Applied voltage: polymer jet initiated at 2 kV and dispensed at 0.8-1kV x-y stage velocity: around 400mm/s Fiber Diameter: 200-350nm Distance between adjacent fibers: 5 μm	[6]

Continued on next page

<i>Table 1 continued</i>				
Poly(ethylene oxide) (PEO)	Deionized water and the ethanol with a volume ratio of 3:1	Airflow-assisted Electrohydrodynamic Direct-writing (EDW)	Solution Concentration: 8wt% PEO Nozzle: Outer airflow passage diameter: 1mm Airflow gas pump pressure: 25kPa Inner liquid passage diameter: 0.21mm Solution deposition rate: 30 μ L/h Nozzle-to-substrate distance: 2mm Substrate composition: Silicon Applied voltage: about 2kV x-y stage velocity: 1-20mm/s Fiber Diameter: 3.73 \pm 1.37 μ m Distance between adjacent fibers: 5.13 \pm 6.67 μ m	[7]
Poly(Vinylidene Fluoride) (PVDF)	Acetone and Dimethyl Sulfoxide (DMSO)	3D Electrospinning	Solution Concentration: 17wt% PVDF; 1.7g of PVDF, 5g of acetone, 0.5g of Capstone FS-66, 5g of DMSO Nozzle: Needle inner diameter of 100 μ m Solution deposition rate: 14 nL/min Nozzle-to-substrate distance: 750 μ m Substrate composition: A4 size commercial printing paper (Double A) Applied voltage: 1.9kV x-y stage velocity: 10mm/s Fiber Diameter: Not determined Distance between adjacent fibers: Not determined	[8]

Continued on next page

<i>Table 1 continued</i>	
	Solution Concentration: Nozzle: Solution deposition rate: Nozzle-to-substrate distance: Substrate composition: Applied voltage: x-y stage velocity: Fiber Diameter: Distance between adjacent fibers:
	Solution Concentration: Nozzle: Solution deposition rate: Nozzle-to-substrate distance: Substrate composition: Applied voltage: x-y stage velocity: Fiber Diameter: Distance between adjacent fibers:
	Solution Concentration: Nozzle: Solution deposition rate: Nozzle-to-substrate distance: Substrate composition: Applied voltage: x-y stage velocity: Fiber Diameter: Distance between adjacent fibers:
	Solution Concentration: Nozzle: Solution deposition rate: Nozzle-to-substrate distance: Substrate composition: Applied voltage: x-y stage velocity: Fiber Diameter: Distance between adjacent fibers:

Continued on next page

<i>Table 1 continued</i>	
	Solution Concentration: Nozzle: Solution deposition rate: Nozzle-to-substrate distance: Substrate composition: Applied voltage: x-y stage velocity: Fiber Diameter: Distance between adjacent fibers:
	Solution Concentration: Nozzle: Solution deposition rate: Nozzle-to-substrate distance: Substrate composition: Applied voltage: x-y stage velocity: Fiber Diameter: Distance between adjacent fibers:
	Solution Concentration: Nozzle: Solution deposition rate: Nozzle-to-substrate distance: Substrate composition: Applied voltage: x-y stage velocity: Fiber Diameter: Distance between adjacent fibers:

Lorem ipsum dolor sit amet, consectetur adipiscing elit, sed do eiusmod tempor incididunt ut labore et dolore magna aliqua. Ut enim ad minim veniam, quis nostrud exercitation ullamco laboris nisi ut aliquip ex ea commodo consequat. Duis aute irure dolor in reprehenderit in voluptate velit esse cillum dolore eu fugiat nulla pariatur. Excepteur sint occaecat cupidatat non proident, sunt in culpa qui officia deserunt mollit anim id est laborum.

3. Polymer Solution and Process Parameters

4. Applications

5. Fiber Characterization

6. Conclusion

References

- [1] G. S. Bisht, G. Canton, A. Mirsepassi, L. Kulinsky, S. Oh, D. Dunn-Rankin, M. J. Madou, Controlled Continuous Patterning of Polymeric Nanofibers on Three-Dimensional Substrates Using Low-Voltage Near-Field Electrospinning, *Nano Letters* 11 (4) (2011) 1831–1837. doi:10.1021/nl2006164.
- [2] D. D. Camillo, V. Fasano, F. Ruggieri, S. Santucci, L. Lozzi, A. Camposeo, D. Pisignano, Near-field electrospinning of conjugated polymer light-emitting nanofibers, *Nanoscale* 5 (2013) 11637–11642. doi:10.1039/C3NR03094F.
- [3] C. Chang, K. Limkraiassiri, L. Lin, Continuous near-field electrospinning for large area deposition of orderly nanofiber patterns, *Appl Phys Lett* (2008) 3doi:10.1063/1.2975834.
- [4] Y. Duan, Y. Ding, Z. Xu, Y. Huang, Z. Yin, Helix Electrohydrodynamic Printing of Highly Aligned Serpentine Micro/Nanofibers., *Polymers* 9 (9) (sep 2017). doi:10.3390/polym9090434.
- [5] A. Gupta, A. M. Seifalian, Z. Ahmad, M. J. Edirisinghe, M. C. Winslet, Novel Electrohydrodynamic Printing of Nanocomposite Biopolymer Scaffolds, *Journal of BIOACTIVE AND COMPATIBLE POLYMERS* 22 (2007). doi:10.1177/0883911507078268.
- [6] Y. Huang, Y. Duan, Y. Ding, N. Bu, Y. Pan, N. Lu, Z. Yin, Versatile, kinetically controlled, high precision electrohydrodynamic writing of micro/nanofibers, *Scientific Reports* 4 (1) (2015) 5949. doi:10.1038/srep05949.
- [7] J. Jiang, X. Wang, W. Li, J. Liu, Y. Liu, G. Zheng, J. Jiang, X. Wang, W. Li, J. Liu, Y. Liu, G. Zheng, Electrohydrodynamic Direct-Writing Micropatterns with Assisted Airflow, *Micromachines* 9 (9) (2018) 456. doi:10.3390/mi9090456.
- [8] J. Kim, B. Maeng, J. Park, Characterization of 3D electrospinning on inkjet printed conductive pattern on paper, *Micro and Nano Systems Letters* 6 (1) (2018) 12. doi:10.1186/s40486-018-0074-1.